



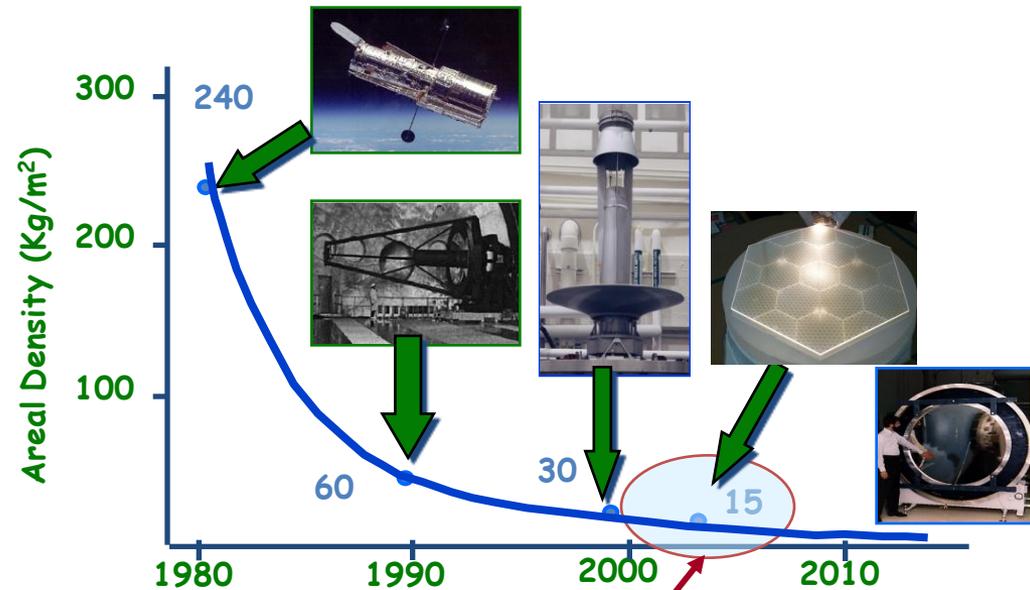
RAPT INDUSTRIES

when speed and precision matter **RAPT Industries**
www.raptindustries.com

Finishing Advanced Mirrors – Answering the Challenge



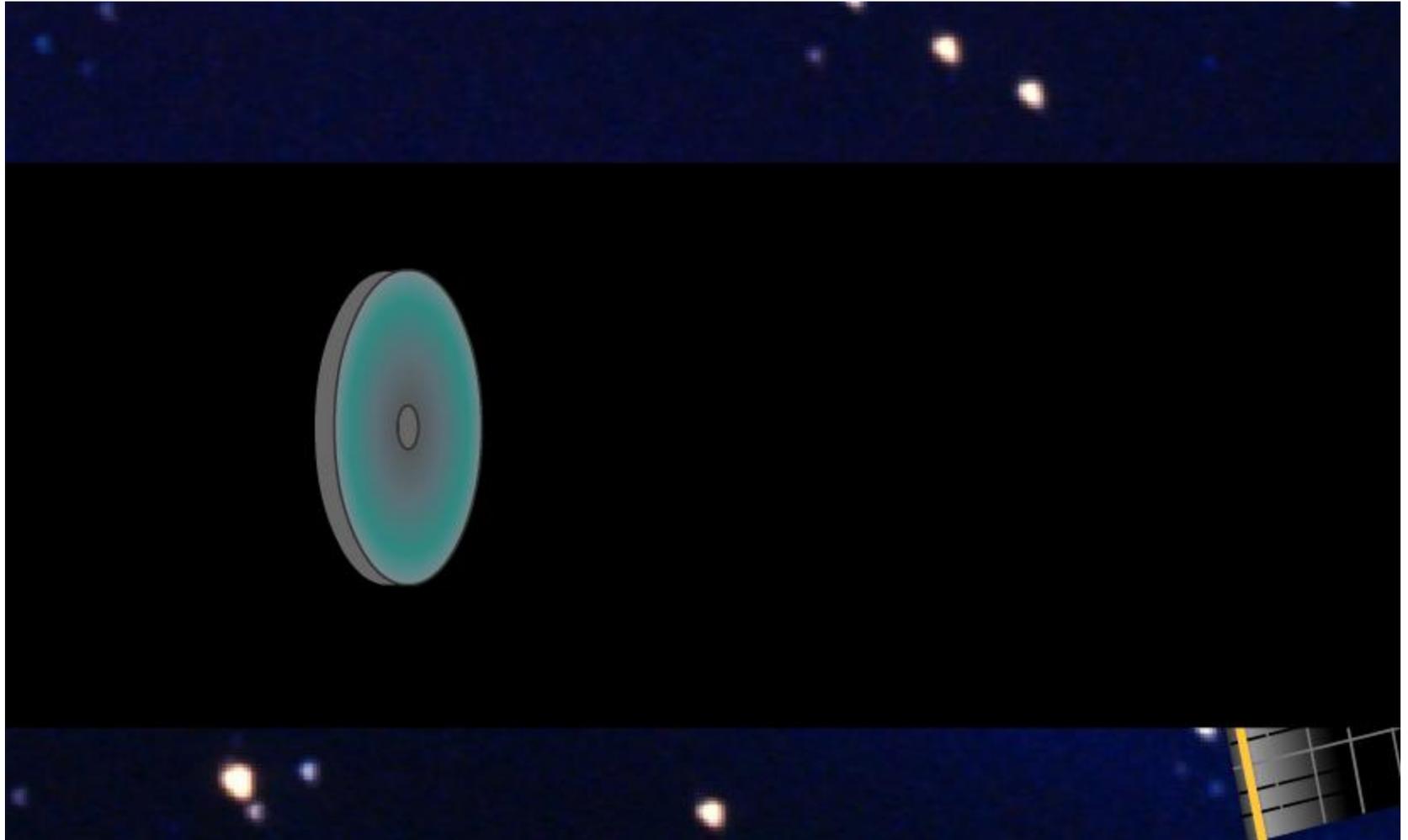
- Aggressive reduction in areal density
- Simultaneous requirement for higher stiffness
 - Exotic geometries/materials
- Aggressive cost reduction
 - Main drivers for cost are lead time (touch time) and risk
- Address Scale-Up Issues
 - Large CAs for better contrast
 - Monoliths are expensive
 - Edge roll issues with segmented designs



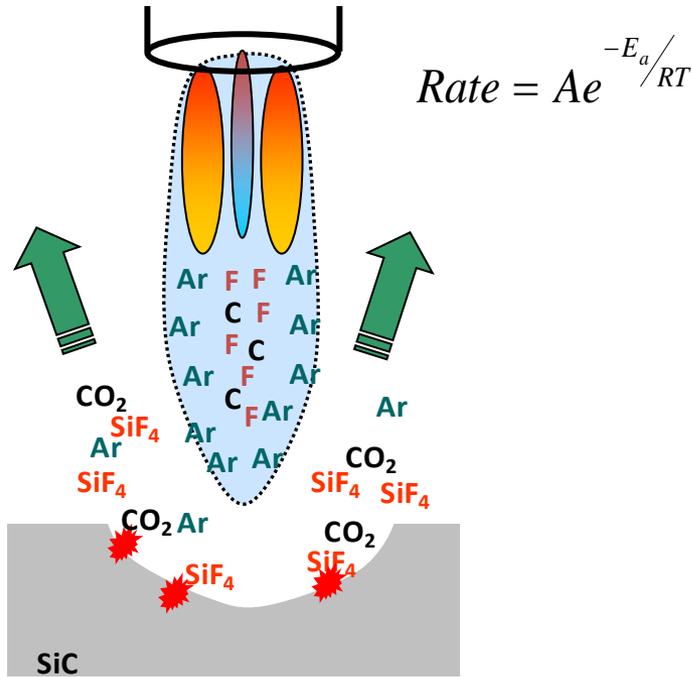
JWST Requirement

RAP™ Integrated
Manufacturing
Process (IMP)

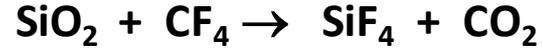
RAP Processing of lightweight mirrors



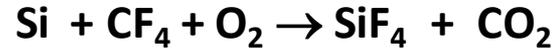
The Chemistry of the Process



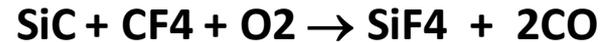
For SiO₂:



For silicon:



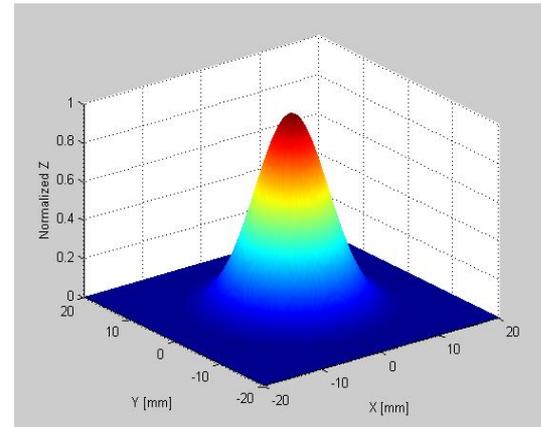
For SiC:



Reaction Products Must be Volatile

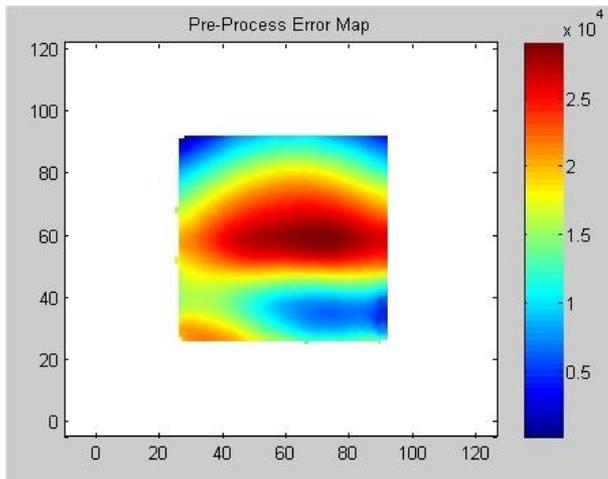
Other plasmas - other materials e.g. Ni, Be, Ti...

- Damage-free figuring @ atmospheric pressure
- Gaussian footprint for chemical figuring tool
 - Arrhenius rate reaction

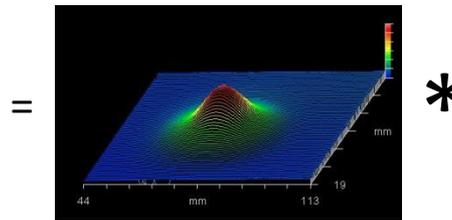


Tool path algorithm

Error Map from Metrology



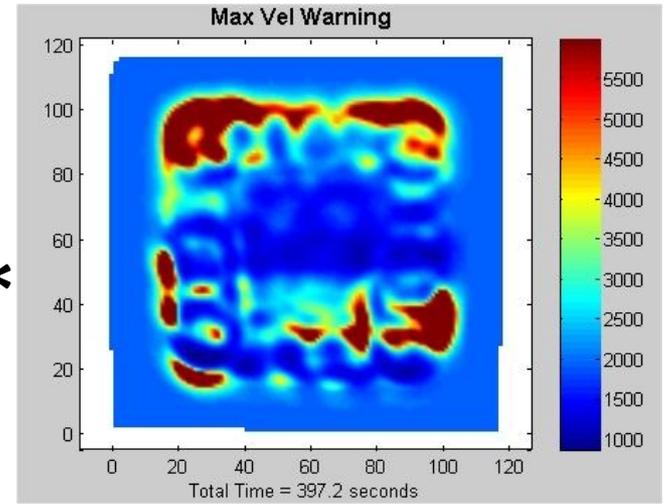
RAP tool shape



=

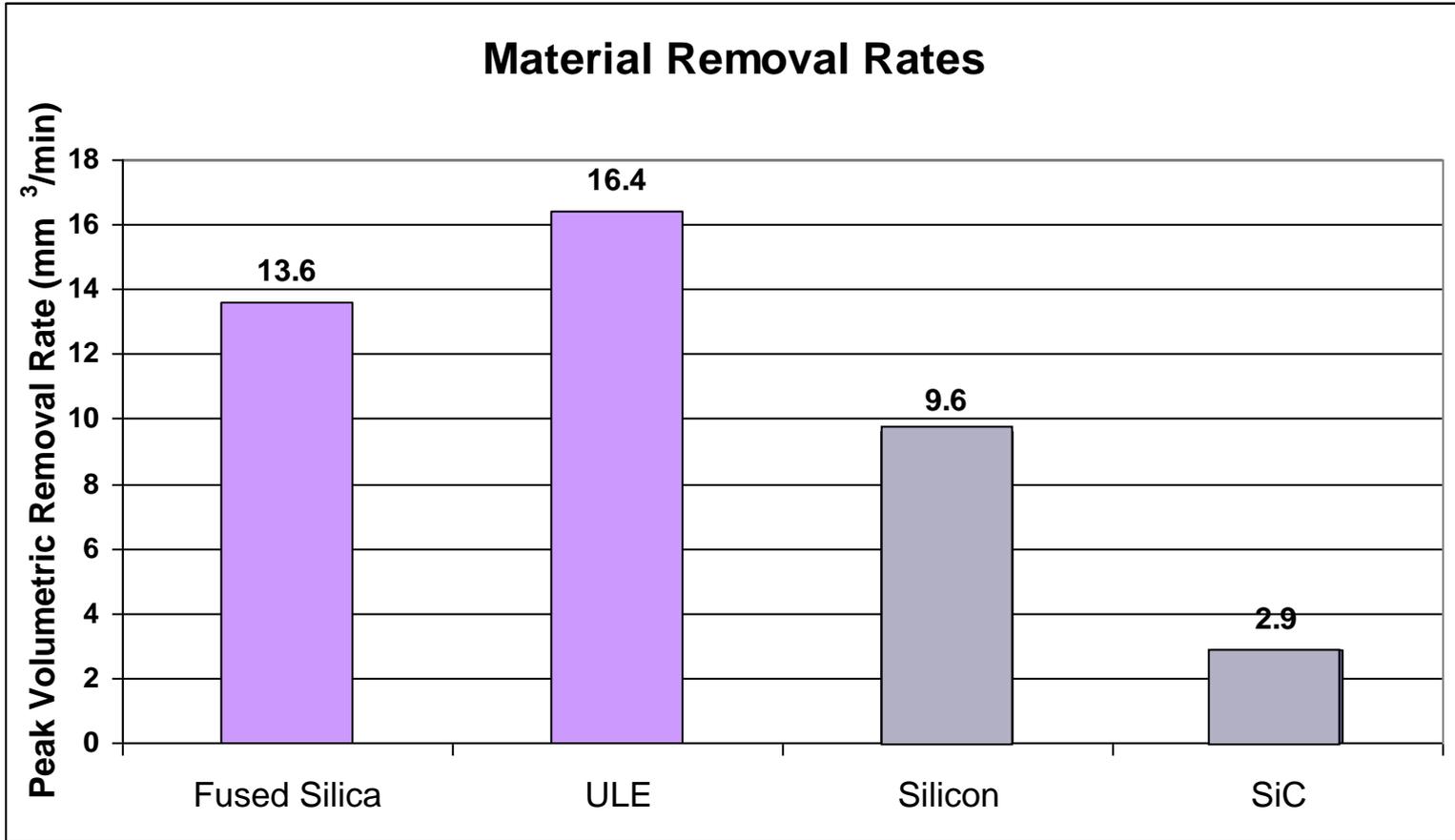
*

Max Vel Warning



Calculated Velocity Map
(red means less dwell time)

RAP Material Removal Rate

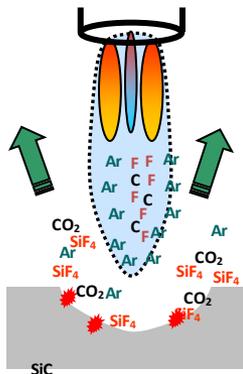


Rapid, Damage-Free Precision Surfaces - The IMP toolbox



Chemical Figuring

- Non-contact
- Atmospheric Pressure
- Damage Mitigation
- Scalable
- Progressive roughening possible for polycrystalline substrates



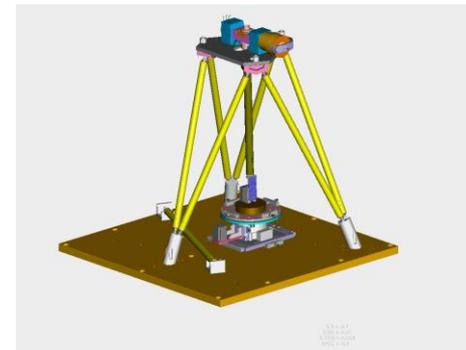
Conformal Buffing

- Pitch tiles to provide state of the art roughness
- Lap stiffness controlled to provide conformal behavior at low/mid spatial frequencies
- Low contact force

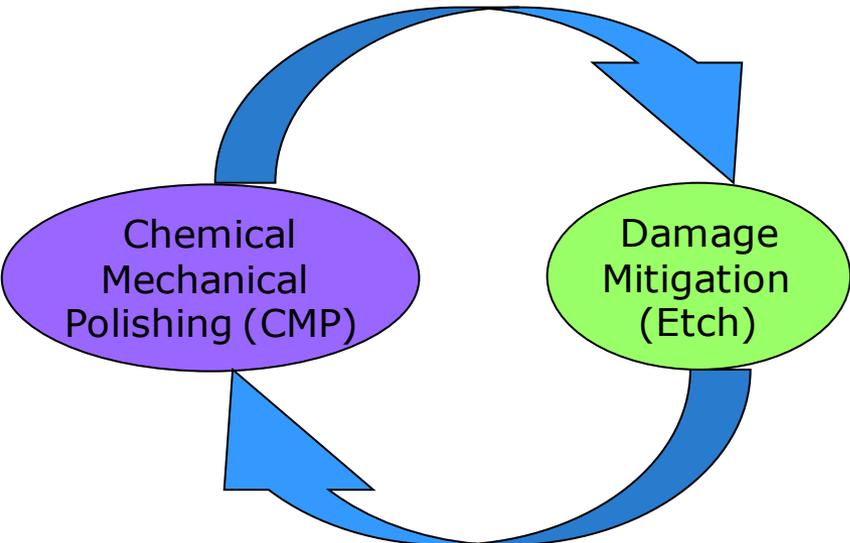


High Density Metrology

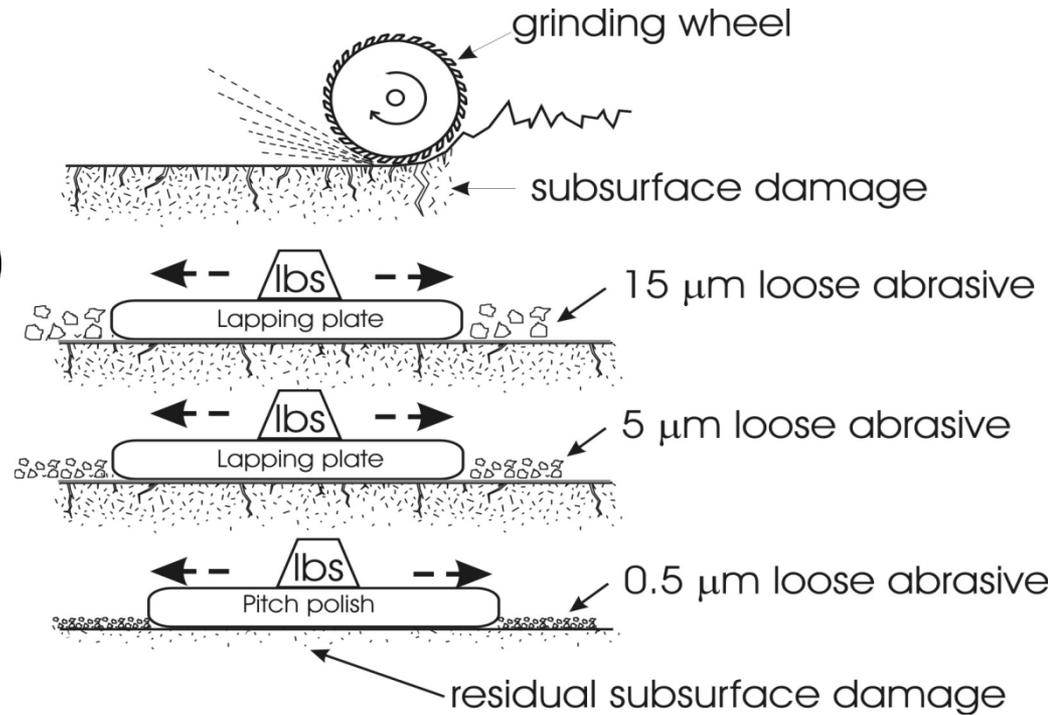
- Rapid collection of dense data
- Fast setup – reference to a mechanical sphere
- Seamless integration into tool path algorithm



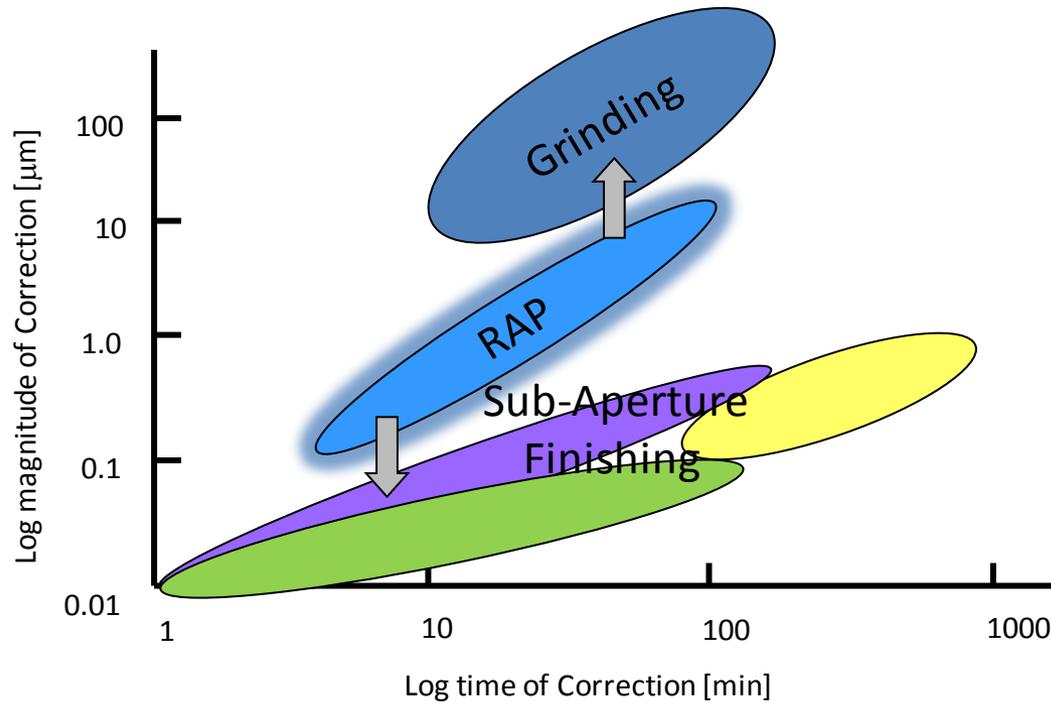
Mitigating subsurface damage during optics fabrication



Conventional



RAP Benefits



- **Force-free Processing**

- No stress imparted
- Deterministic convergence for high aspect ratio (low areal density) optics
- No stiffness requirements on large tools
- Allows the manufacturing of precise surfaces with low-cost imprecise tools

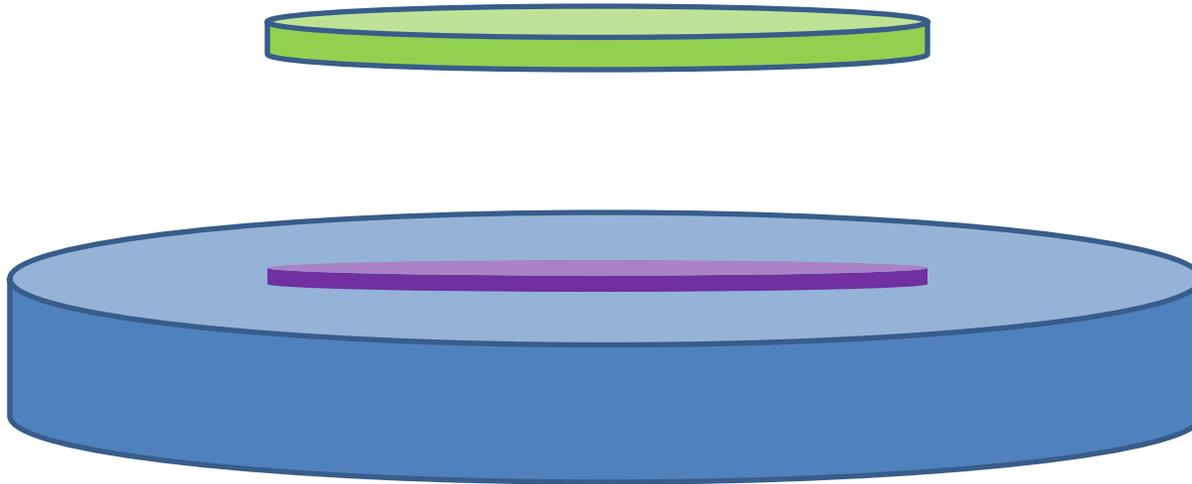
- **Atmospheric Pressure Process**

- Vacuum Processing has scalability concerns, cycle time issues
 - Ion-beam milling

- **Eliminates/Minimizes SSD**

- Contact Processing techniques impart SSD to surface
- Reduction in tensile strength of optic
 - Chemical Mechanical Polishing
 - Single point diamond turning

Twyman Experiment Methodology



$$\sigma = \frac{4 \delta E d^2}{3(1-\nu) t D^2}$$

σ = Tymann stress (unknown)

ν = Poisson's Ratio

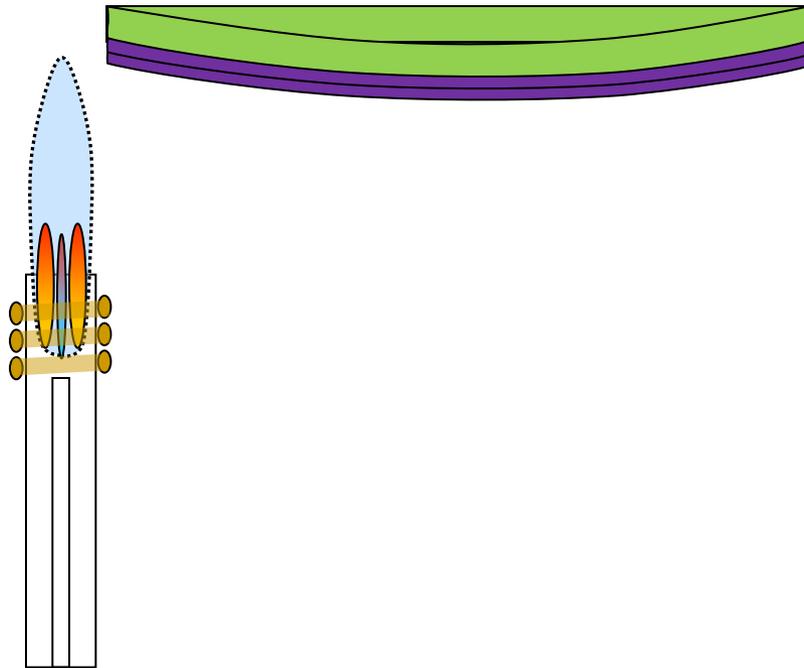
E = Young's Modulus

t = Damage layer thickness (unknown)

d = Substrate thickness

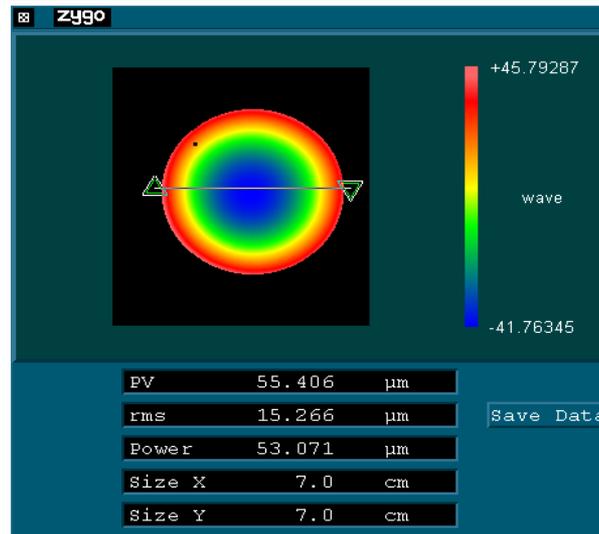
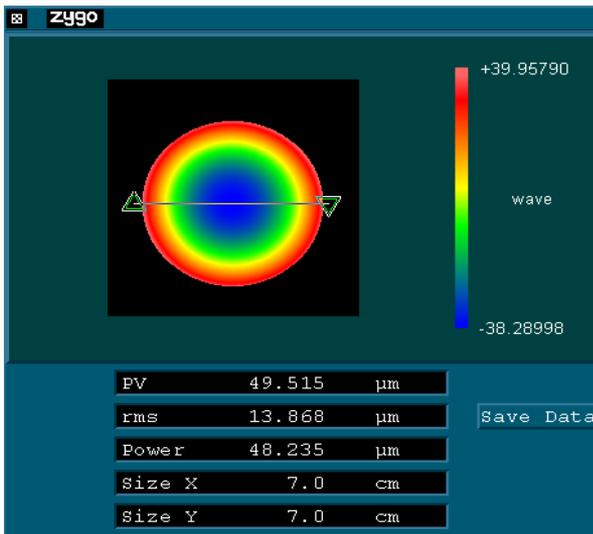
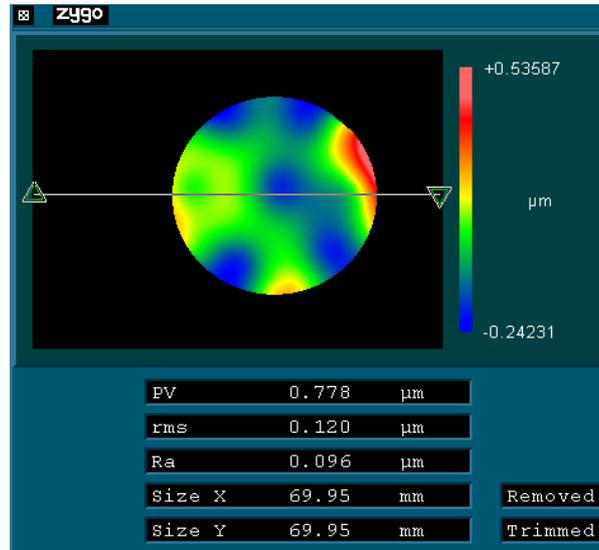
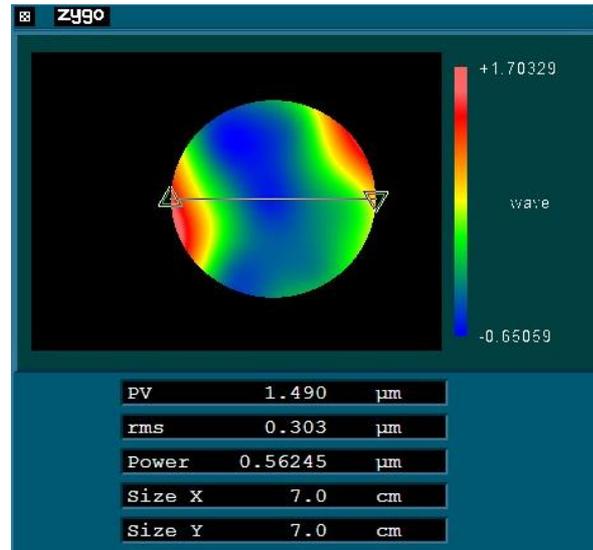
D = Substrate Diameter

δ = Circular plate deflection (or Sag)



SSD from Milling

Before Milling

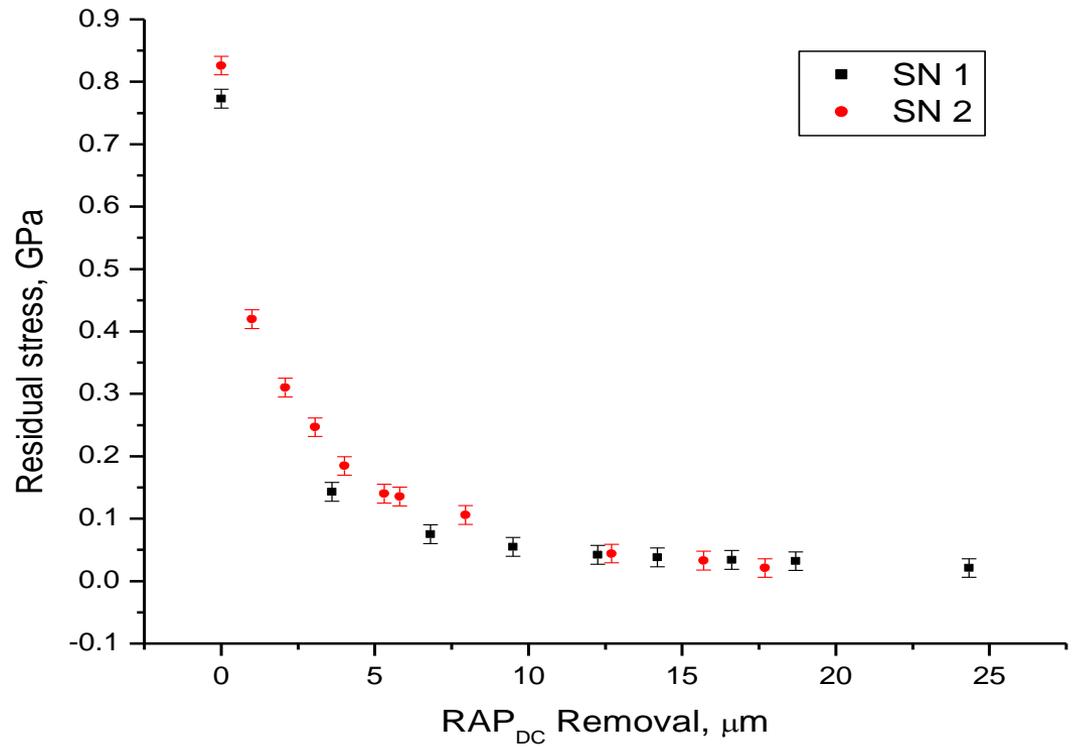
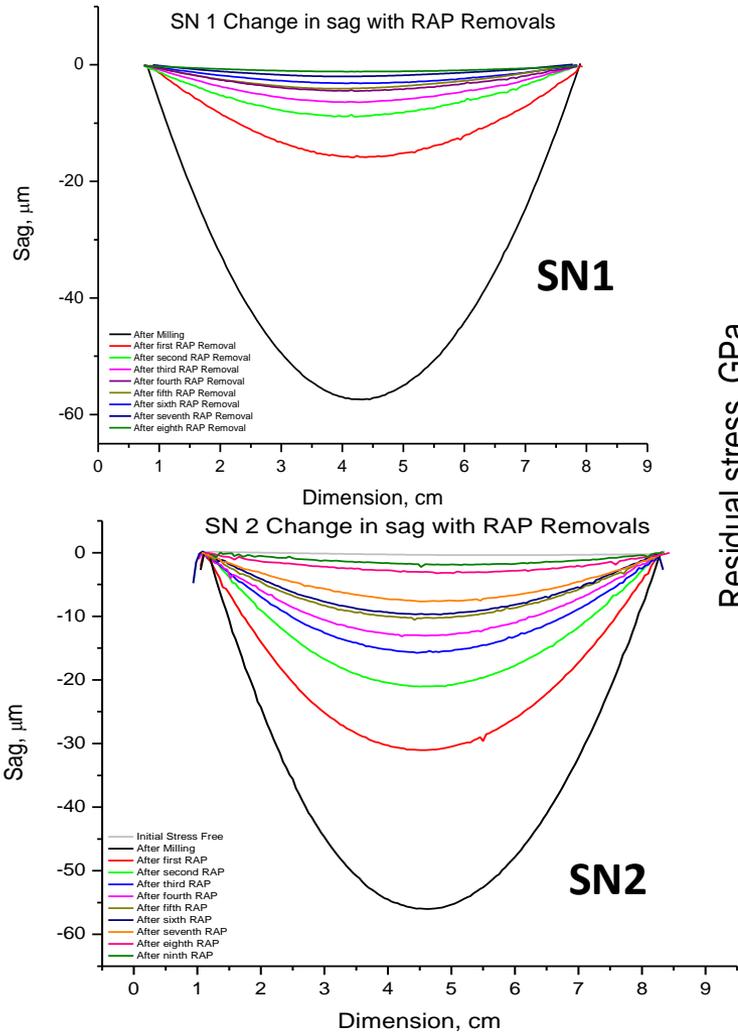


SN1

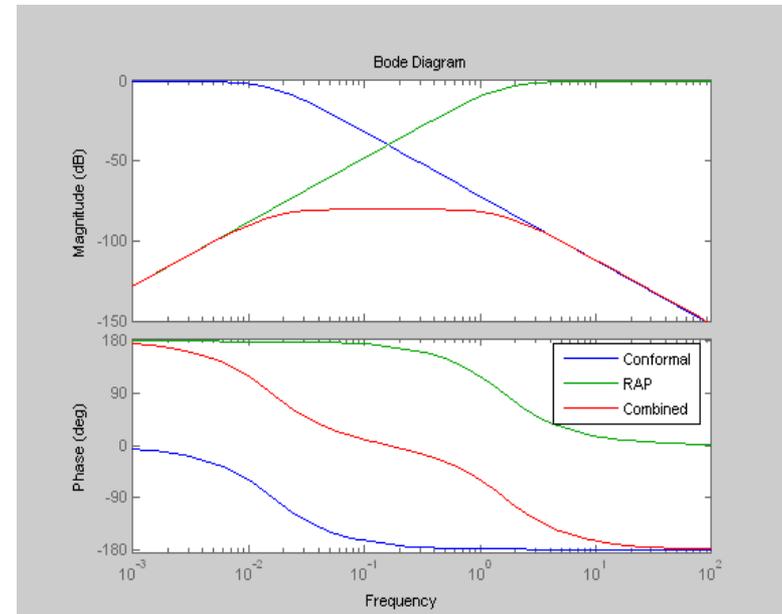
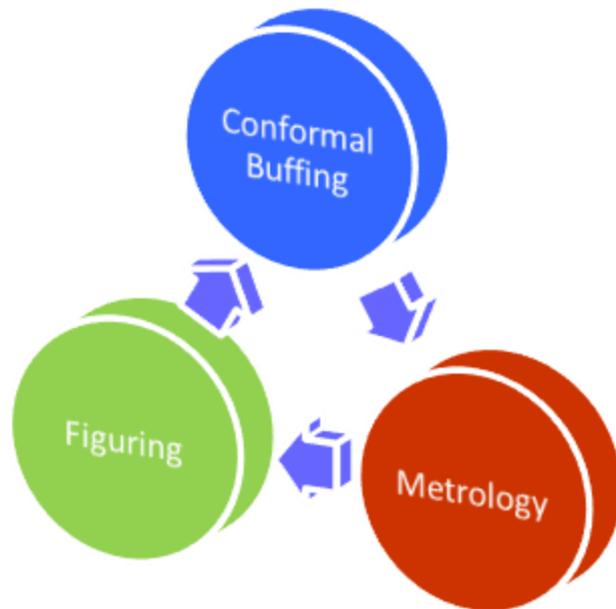
SN2

After Milling

Stress reduction through RAP™



RAP IMP – Application to SiC



- High activation energy for SiC – thermal management during figuring critical
- Considerable knowhow to minimize edge-effects
- RAP to address opportunity through manufacturing services out of PA
- Polycrystalline/multi-phase materials roughen up, iteration between figuring and buffing needed to obtain desired figure/roughness
- 150th wave RMS figure and 3 Angstroms RMS roughness achieved repeatably

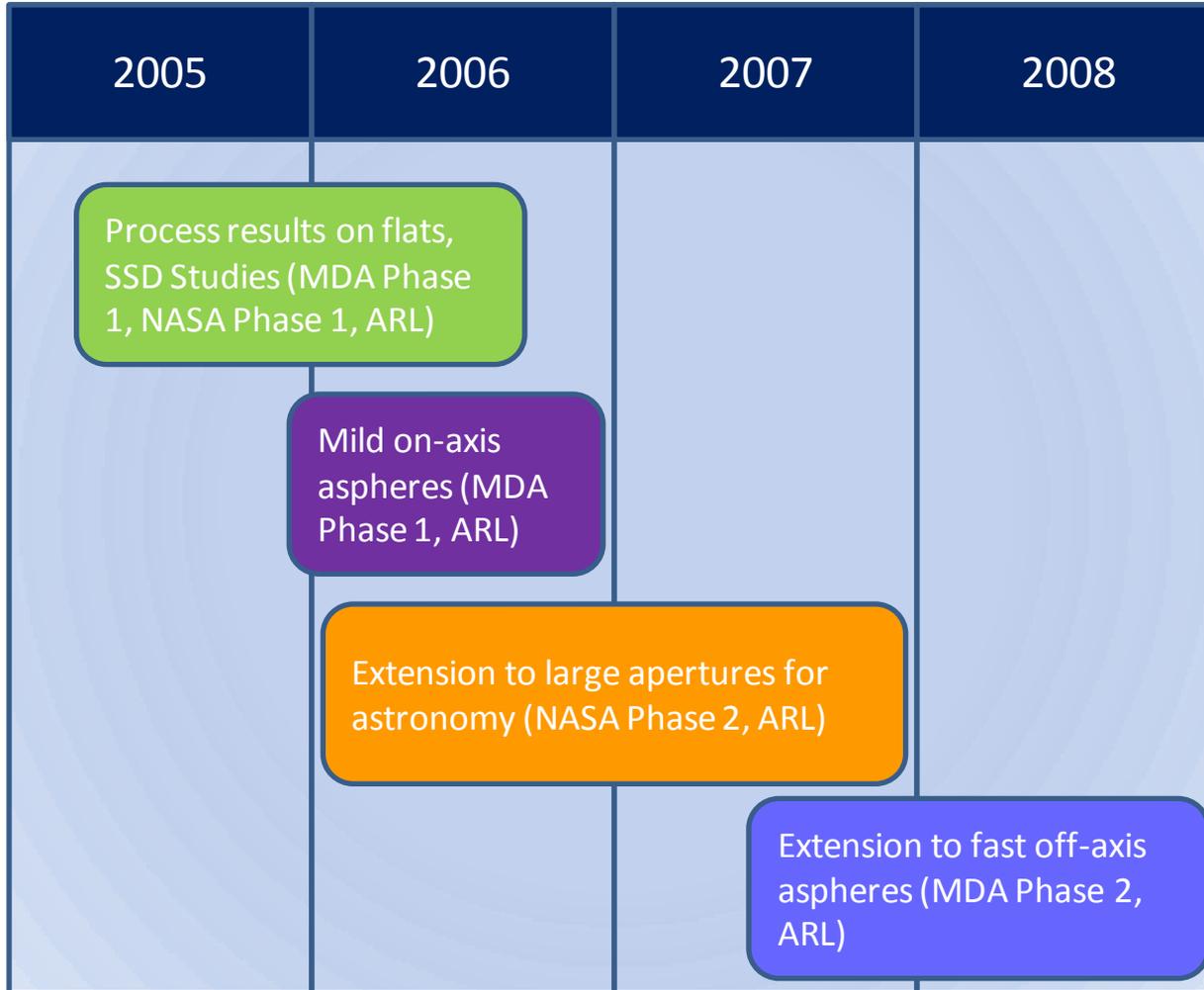
On-Axis SiC parabola for Ball Aerospace



- On-axis SiC f/2.25 parabola
- 200 mm clear aperture
- Finished to 0.050λ RMS
- Roughness of 3.3A RMS
- Asphere figuring in 3 weeks
- Can achieve figure errors of 0.010λ RMS



Our Programs



- W911NF-04-2-0001 – Army Research Laboratory
COTR: Dr. Jane Adams
- NNM06AA11C – NASA Phase 2 SBIR – MSFC
COTR: Mr. John West
- W9113M-07-C-0149 – MDA Phase 2 SBIR – AFRL
COTR: Dr. Larry Matson

Gap in developing scalable thermal strategies – Needed for large SiC mirrors

Current Projects - ARL

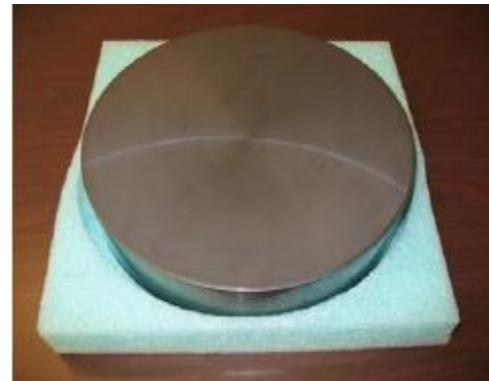


- Army Research Lab
 - Multi-year project to develop RAP process for rapid production of SiC optics
 - Current year program primarily focused on equipment development
 - Third generation prototype RAP system design and build
 - Process characterization
 - Hardware/Software enhancement
 - Plasma process
 - Coarse metrology
 - Algorithms

Current Projects - NASA



- NASA SBIR Phase II
 - Objective: To demonstrate IMP on powered SiC optics
 - Tasks:
 - Develop design for lightweight SiC optics
 - Comparable to JWST segments
 - Optimize process for powered mirrors
 - Produce 300mm aspheres (on-axis)
 - Study scale-up to 1 meter class mirrors

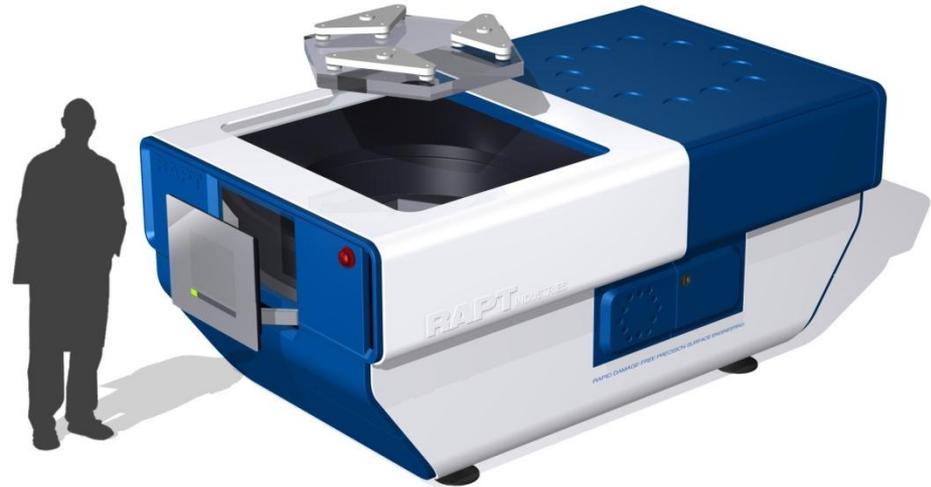
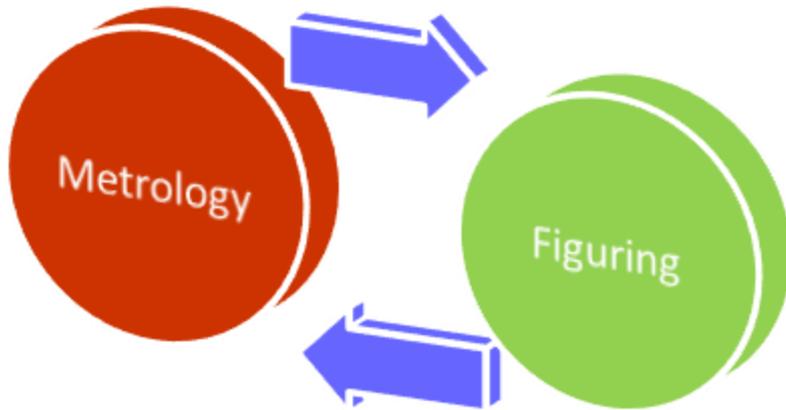


Current Projects - MDA



- MDA SBIR Phase II
 - Extend IMP to the production of fast, off-axis SiC aspheres
 - Target design: ~300mm diameter f/1 off-axis parabola
 - Development Tasks:
 - Apply RAP to steeply curved surfaces
 - Profilometry of fast off-axis aspheres
 - Demonstrate deterministic sub-aperture figuring processes

RAP IMP – Application to “Glass”

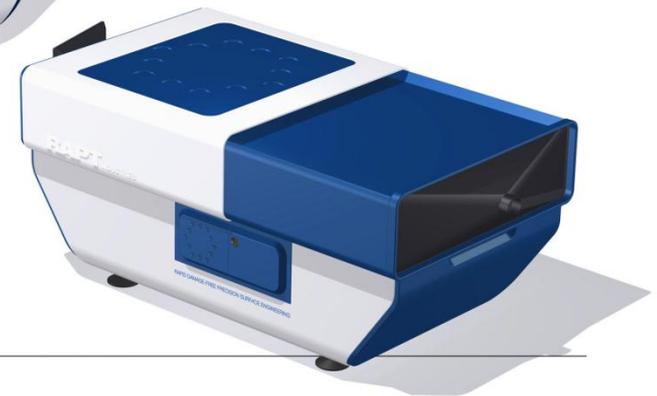
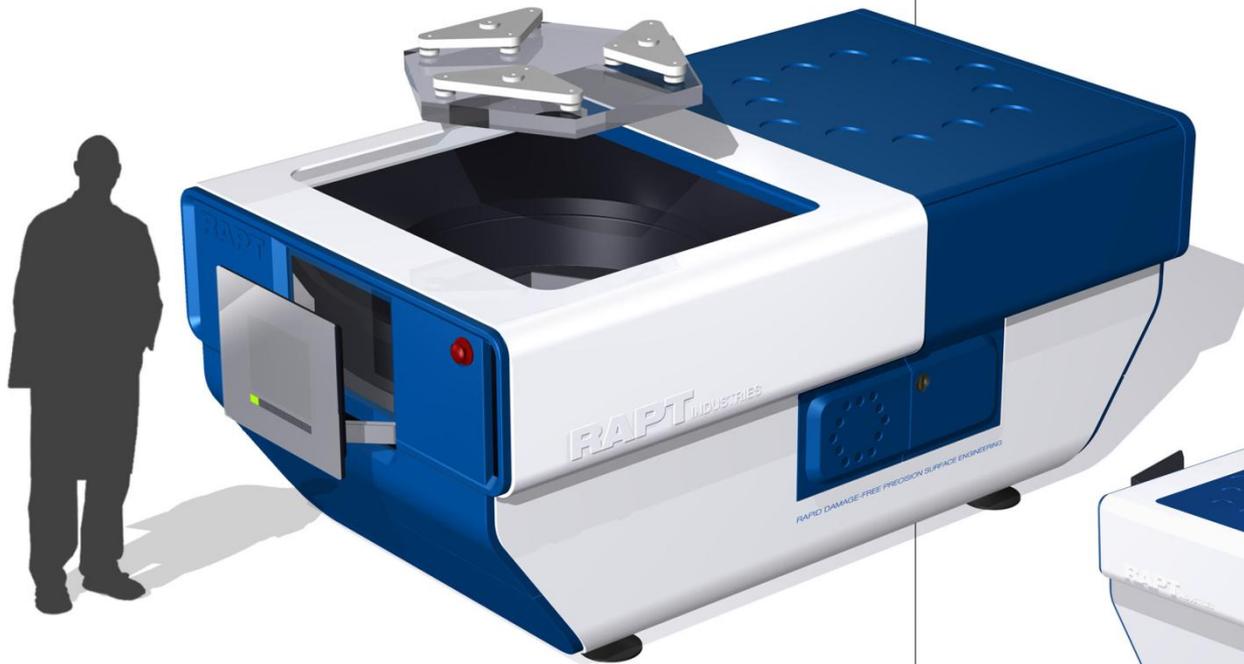


- Lower activation energy for “Glass” materials permits “cool” operation
- Fine, highly deterministic figuring runs at atmospheric pressure lead to very little change in surface roughness
- RAPT to address opportunity through the sale/lease of highly automated tools

Results on Glass/Glass-Ceramics



- Currently in preliminary stages of assessing RAP etching of various mirror substrate materials
 - Fused quartz extensively studied
 - Pyrex successfully aspherized
 - Figuring of ULE in progress
 - Preliminary results on Zerodur look promising
- For these materials, surface roughening during RAP is related to SSD
 - Well-prepared surfaces do not get significantly rougher with etching

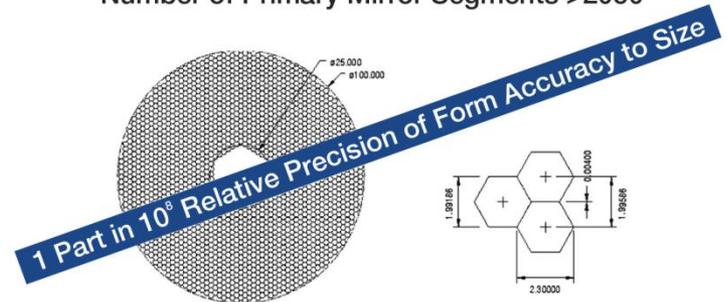


Large format “Reactive Atom Plasma (RAP™) Processing Machine”

- >Meter class optics figuring
- >Precision material removal, 10 nm to 10 micron
- >Ability to work common optical materials
- >Sub-surface damage mitigation
- >Competitive material removal rates
- >Non-contact processing at atmospheric pressure

Developed in Collaboration with **Cranfield UNIVERSITY**

Number of Primary Mirror Segments >2050

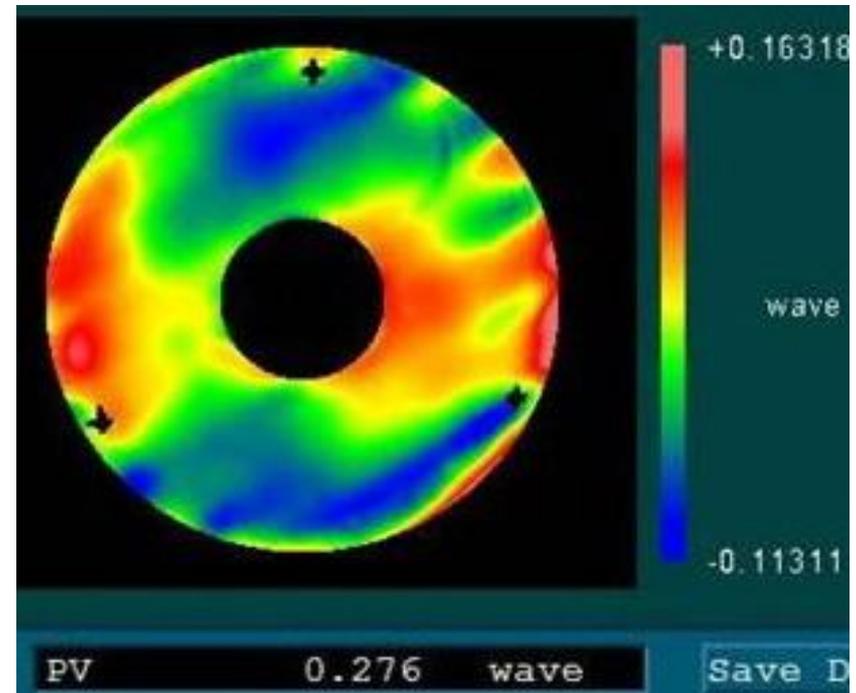


OWL Primary Mirror

Form Accuracy 25 nm
Roughness <1 nm

Conclusions

- RAP Processing is effective for damage-free shaping of SiC
- Integrated Manufacturing Process has been used to rapidly produce several aspheres
- Ongoing programs with ARL/NASA/MDA are providing advances in both process and equipment
- Production of fast, off-axis aspheres is coming
- Application of IMP to glass and glass-ceramic mirror materials is showing significant promise



8" lightweight SiC asphere (parabola, f/4) finished to 0.27λ PV